



TRIBOLOGY INTERNATIONAL CONFERENCE



SICT 2022 / PLASMA TECH 2022 / TRIBOLOGY 2022 HYBRID JOINT CONFERENCES

27-29 Avril, 2022 - Barcelona, Spain

Book of Abstracts

Organizer



28 April 2022

Plasma Tech Session II: Plasma Processing / materials interactions / coatings

Onsite Conference Room Glorias A Session's Chairs: Prof. Mark J. Kushner, University of Michigan, USA Prof. Vasco Guerra, Technical University of Lisbon, Portugal Selectively changing key surface properties via atmospheric Dr. Thomas Danny Michl, gliding arc plasma deposition University of Applied Sciences 09:00 - 09:30 T. Danny Michl, A. Goel and S. Neuhaus Northwestern and Arts Switzerland, Switzerland On the formation of carbon nanoparticles in expanding laser-Ms. Agata Kaczmarek. induced plasma Fundamental Institute of 09:30 - 09:45 A. Kaczmarek and J. Hoffman Research Technological Polish Academy of Sciences, **Poland** Carbon nanostructure production from ethanol by cold plasma Dr. Andrea Jurov, University 09:45 - 10:00 A. Jurov, J. Zavašnik and U. Cvelbar of Zagreb, Croatia Hydrophobic and Amphiphobic Postmodification of Mesoporous Baldur Schroeter. 10:00 - 10:15 Aerogels via Cold Plasma Coating University Hamburg B. Schroeter, I. Jung, P. Gurikov and I. Smirnova Technology, Germany Plasma Activated Liquids: a Method for Efficient Surface Modifica-Dr. Pavel Galář, Institute of tion of Semiconductor Nanostructures Physics of the Czech 10:15 - 10:30 P. Galář, F. Matějka, J. Khun and K. Kůsová Academy of Sciences, Czech Republic 10:30 - 11:00 **Coffee Break** UV-LED, UV-laser and Corona discharge treatments for Mrs **Beatrice** Malchiodi, polypropylene surface functionalization and optimization of PP-University of Modena and 11:00 - 11:15 Fiber Reinforced Concrete Reggio Emilia, Italy B. Malchiodi, P. Pozzi and C. Siligardi Fast Switch From Hydrophilic to Hydrophobic Surface of Cellulose Ms Ana Oberlintner. National 11:15 - 11:30 Film by Low-Temperature Plasma Treatment Institute Chemistry, of A. Oberlintner, V. Shvalya, B. Likozar and U. Novak Slovenia Recent progress in the electrical management of the plasma Dr Julien Martin. University electrolytic oxidation process of Lorraine, France 11:30 - 11:45 J. Martin, V. Ntomprougkidis, C. Tousch, A. Maizeray, G. Marcos, T. Czerwiec, T. Belmonte and G. Henrion Promoting resource preservation by PECVD barrier coatings for Dr. Philipp Alizadeh, RWTH 11:45 - 12:00 refillable PET bottles Aachen University, Germany P. Alizadeh and R. Dahlmann Cathodic plasma electrolytic deposition of an aluminium oxide Wetegrove, Marcel Dr. based hydrogen permeation barrier Leibniz Institute for Plasma

M. Wetegrove, M. Rohloff, U. Lindemann, A. Quade and A. Kruth

Lunch Break

12:00 - 12:15

12:00 - 14:00

Technology.

Science

Germany

and

On the formation of carbon nanoparticles in expanding laser-induced plasma

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Abstract:

Nowadays, there are numerous works devoted to characterizing the properties of carbon nanoparticles obtained by laser ablation in various media, e.g. in liquid [1]. Therefore, it is possible to optimize and control the size of particles, their optical and morphological properties and link them with synthesis parameters, such as the kind of liquid medium or laser fluence. However, the description of primary formation processes of carbon nanoparticles after laser ablation in vacuum, gas or liquid remains incomplete [2].

There have been several attempts to describe the formation of carbon nanoparticles. One of them [3] considered the entire lifecycle of carbon ablation plasma. According to this study, nanoparticles are formed as a result of the ejection of fragments of the target (graphite). Another possibility is ejection of liquid droplets as an effect of so called phase explosion and explosive boiling [4]. Other studies postulate that nanoparticles are formed during plasma-phase expansion [2, 5] and that this process can be divided into two two main phases: (1) nucleation and (2) growth and crystallization.

The aim of this work is to analyze possible nucleation and growth paths of particles in carbon plasma. The consideration of nucleation type is based on the following equation:

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$$\Delta G = -\frac{4\pi r^3}{3V} kT \ln S + 4\pi r^2 \gamma,$$

where ΔG is Gibbs free energy, r nucleus size, V volume occupied by the single atom or molecule in nucleus, T is temperature, S supersaturation ratio and γ surface tension [2].

Further modifications to the above equation are made to account for ion nucleation. It has been found that in the case of carbon plasma the purely thermodynamic approach of continuous media is insufficient. It is necessary to include in the considerations various kinds of carbon macromolecules.

Moreover, the discussion of the conditions for the formation of particles solely from the expanding plasma and the avoidance of their ejection from the target is presented.

Keywords: nanoparticles, carbon dots, laser ablation, nucleation, ion-induced nucleation.

References:

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- 2. Taccogna, F. (2015), Nucleation and growth of nanoparticles in a plasma by laser ablation in a liquid, *J. Plasma Phys.*, 81, 495810509.
- 3. Harilal, S.S., Hassanein, A., Polek, M. (2011), Late-time particle emission from laser-produced graphite plasma, *J. Appl. Phys.*, 110, 053301.
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